



REPLY UNDER 37 C.F.R. § 1.116 EXPEDITED PROCEDURE EXAMINING GROUP 1752

> PATENT 2224-0163P

BOX AF

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant:

Tatsuya NAKANO

Conf.:

5816

Appl. No.:

09/463,059

Group:

1752

Filed:

January 19, 2000

Examiner: THORNTON

For:

ACID-SENSITIVE COMPOUND AND RESIN

COMPOSITION FOR PHOTORESIST

LARGE ENTITY TRANSMITTAL FORM FOR REPLY AFTER FINAL UNDER 37 C.F.R. § 1.116

BOX AF

Assistant Commissioner for Patents Washington, DC 20231

February 19, 2003 (Day After Holiday)

Sir:

Transmitted herewith is an amendment in the above-identified application.

The enclosed document is being transmitted via the Certificate of Mailing provisions of 37 C.F.R. § 1.8.

The enclosed document is being transmitted via facsimile.

The fee has been calculated as shown below:

	CLAIMS REMAINING AFTER AMENDMENT		HIGHEST NUMBER PREVIOUSLY PAID FOR		PRESENT EXTRA	RATE	ADDITIONAL FEE
TOTAL	12	-	20	=	0	\$ 18	\$0.00
INDEPENDENT	2	-	3	=	0	\$ 84	\$0.00
FIRST PRESENTATION OF A MULTIPLE DEPENDENT CLAIM						\$280	\$0.00
BAIGUYEN1 00000093 09463059						TOTAL	\$0.00

02/20/2003 BNGUYEH1 00000093 0946

410.00 OP

01 FC:1252

Appl. No. 09/463,059

(Rev. 09/30/02)

	Petition for two (2) month(s) extension of time pursuant to 37 C.F.R. §§ 1.17 and 1.136(a). \$410.00 for the extension of time.	
	No fee is required.	
\boxtimes	Check(s) in the amount of \$410.00 is(are) enclosed.	
	Please charge Deposit Account No. 02-2448 in the amount of \$0.00. This form is submitted in triplicate.	
overn requi	If necessary, the Commissioner is hereby authorized in this, arrent, and future replies, to charge payment or credit any payment to Deposit Account No. 02-2448 for any additional fees ared under 37 C.F.R. §§1.16 or 1.17; particularly, extension of fees.	
	Respectfully submitted,	
	BIRCH, STEWART, KOLASCH & BIRCH, LLP	
Ĺ	By A A A A A A A A A A A A A A A A A A A	18/
•	RG:gml Falls Church, VA 22040-0747	
2224	-0163P (703) 205-8000	
Attac	chment(s)	



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AMENDMENT UNDER 37 CFR 1.116

BOX AF

Assistant Commissioner for Patents

Washington, DC 20231

February 19, 2003 (Day after Holiday)

Sir:

Responsive to the Office Action of September 16, 2002, the period for responding having been extended two (2) months until Sunday, February 16, 2003, please enter the following amendments and remarks into the file of the above-identified application.

IN THE CLAIMS:

Cancel claims 5-7, without disclaimer or prejudice.